

Editorial

Acknowledgement to Reviewers of *Journal of Low Power Electronics and Applications* in 2018

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Rigorous peer-review is the corner-stone of high-quality academic publishing. The editorial team greatly appreciates the reviewers who contributed their knowledge and expertise to the journal's editorial process over the past 12 months. In 2018, a total of 47 papers were published in the journal, with a median time to first decision of 17 days and a median time to publication of 40 days. The editors would like to express their sincere gratitude to the following reviewers for their cooperation and dedication in 2018:

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